



UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/955,600	09/19/2001	Nobuhiko Hayashi	990852A	1668
38834	7590 03/05/2004		EXAMINER	
WESTERM	IAN, HATTORI, DAN	NGUYEN,	NGUYEN, TUAN H	
1250 CONNECTICUT AVENUE, NW SUITE 700			ART UNIT	PAPER NUMBER
	ON, DC 20036		2813	

DATE MAILED: 03/05/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

				A S			
		Application No.	Applicant(s)	<i>,</i> • • • • • • • • • • • • • • • • • • •			
Office Action Summary		09/955,600	HAYASHI ET AL.				
		Examiner	Art Unit				
		Tuan H. Nguyen	2813				
Period fo	The MAILING DATE of this communication ap or Reply	pears on the cover sh	eet with the correspondence ac	idress			
THE I - Exter after - If the - If NO - Failu Any r	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1. SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a represent of the reply is specified above, the maximum statutory period re to reply within the set or extended period for reply will, by statutely received by the Office later than three months after the mailing patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, bly within the statutory minimu will apply and will expire SIX e, cause the application to be	, may a reply be timely filed m of thirty (30) days will be considered time (6) MONTHS from the mailing date of this o come ABANDONED (35 U.S.C. § 133).	ly. communication.			
Status							
1)⊠	Responsive to communication(s) filed on 30 L	December 2003.					
	•	s action is non-final.					
3) 🗌	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Dispositi	on of Claims		-				
5)□ 6)⊠ 7)□	Claim(s) 1-3 and 12-17 is/are pending in the a 4a) Of the above claim(s) 1-3 and 14-17 is/are Claim(s) is/are allowed. Claim(s) 12-13 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/	e withdrawn from con	-				
Applicati	ion Papers						
10)□	The specification is objected to by the Examin The drawing(s) filed on is/are: a) acceptable and applicant may not request that any objection to the Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the Examination.	cepted or b) object e drawing(s) be held in ction is required if the d	rawing(s) is objected to. See 37 C				
Priority (under 35 U.S.C. § 119						
12) ☑ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) ☑ All b) ☐ Some * c) ☐ None of: 1. ☐ Certified copies of the priority documents have been received. 2. ☑ Certified copies of the priority documents have been received in Application No. ② (34,246.) 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
Attachmen	t(s)						
2) Notice	te of References Cited (PTO-892) te of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 or No(s)/Mail Date	Pa 3) 5) 🔲 No	erview Summary (PTO-413) per No(s)/Mail Date tice of Informal Patent Application (PT ner:	O-152)			

Application/Control Number: 09/955,600

Art Unit: 2813

DETAILED ACTION

Election/Restrictions

This application contains claims 1-3, 14-17 drawn to an invention nonelected with traverse in Paper No. dated 7/14/03. A complete reply to the final rejection must include cancellation of nonelected claims or other appropriate action (37 CFR 1.144) See MPEP § 821.01.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 12-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Wang et al..

Wang, figs. 3A-3F, 7 and text on col. 5-10 discloses the claimed semiconductor including a first nitride base semiconductor layer 70 formed on an insulating substrate 52 (fig. 3A, col. 5, lines 40-60); an irregular pattern including a plurality of recesses and projections being formed in the first nitride base layer 70 (figs. 3B, paragraph bridging col. 5-6, and fig. 7. col. 8, fourth paragraph); insulating film 56 is optionally formed on the bottom surface of a recess and the top surface of a projection of the irregular pattern of the semiconductor layer 70 (fig. 3C, col. 6, third paragraph); a second nitride base semiconductor layer 71 formed on the insulating films 56 containing at least one of 'ium. aluminum and indium; and third nitride based semiconductor layer 72, 73

Application/Control Number: 09/955,600

Art Unit: 2813

formed on the second nitride based semiconductor layer 71 (col. 4, first paragraph, figs. 3E, 3F, col. 6, fourth paragraph).

Wang does not particularly form an active region in the third nitride layer; however, on col. 10, lines 32-34, Wang suggests the step of forming active region in either second layer 71 of third layer 72,73.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have formed active region by introducing suitable dopants in any one of the epitaxial layer as suggested by Wang in order to obtain a desired device.

Response to Arguments

Applicant's arguments filed 12/30/03 have been fully considered but they are not persuasive. Since there is no distinction between the second and the third nitride base layers in the instant claim 12 therefore the top portion of the second layer could be considered as a third layer; secondly the instant claim 12 does not preclude the formation of active region in the second layer, and thirdly Wang clearly suggests to form active region in either second or third nitride base layers 71 or 72, 73 (col. 10, fifth paragraph).

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not

Application/Control Number: 09/955,600 Page 4

Art Unit: 2813

mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuan H. Nguyen whose telephone number is 571-272-1694. The examiner can normally be reached on 9AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Tuan H. Nguyen
Primary Examiner
Art Unit 2813